Supplementary Material

Cyclohexene Epoxidation with H₂O₂ in the Vapor and Liquid Phases over a Vanadium-based Metal-Organic

Framework

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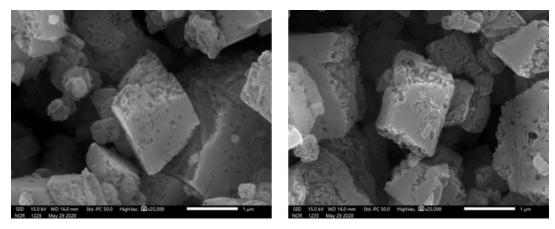
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(a) MIL-47(V) before the epoxidation

(b) MIL-47(V) after the epoxidation

Figure S1. SEM images of MIL-47(V) (a) before and (b) after liquid-phase cyclohexene epoxidation at 65 $^{\circ}$ C.

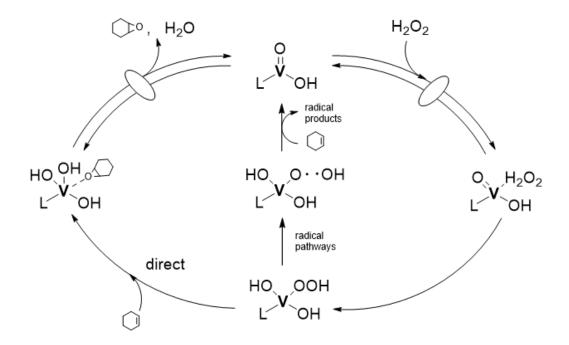


Figure S2. Proposed reaction networks of cyclohexene epoxidation with H₂O₂ over MIL-47(V).

The role of the vanadium node in MIL-47(V) as an active site is proposed. H₂O₂ is first bound to the node, and then forms OOH species. This species can undergo either direct or radical pathways via heterolytic or homolytic cleavage of OOH, respectively. In the former case, cyclohexene is bound to yield epoxide. In the case of radical pathway, cyclohexene reacts with radical and forms cyclohexenyl hydroperoxide, and then yield radical products.